

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
(Attorney Docket No. SEM4492P0020US; Corporate Docket No. P98-0025)

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AS
1/19/00

In the Patent Application of:

Linlin Chen


Serial No.: 09/045,245

Filed: March 20, 1998

For: APPARATUS AND
METHOD FOR
ELECTROLYTICALLY
DEPOSITING COPPER ON A
SEMICONDUCTOR
WORKPIECE

CERTIFICATE OF MAILING

I hereby certify that this
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Assistant Commissioner for Patents,
Washington, DC 20231, on January 10,
2000.


Robert B. Polit
Reg. No. 33,993

Examiner: W. Nicolas

Art Unit: 1741

REQUEST FOR APPROVAL OF DRAWING CHANGES

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated July 9, 1999, Applicant hereby requests that the changes to Figures 2B-2D, as highlighted in the attached drawings, be approved for entry. Such changes bring the Figures into conformance with the corresponding description found on page 11 of the application and do not add new matter.

Further, Applicant requests entry of Figure 7 in the present application. The contents of Figure 7 merely tracks the language describing Figure 7 at p. of the application and does not add new matter.